

**Amendments to the Claims:**

This listing of claims will replace all prior versions, and listings, of claims in the application:

**Listing of Claims:**

1. (Currently Amended) An organic electroluminescence (EL) device comprising:
  - a substrate;
  - a first electrode on the substrate;
  - an organic emitting layer on the first electrode; and
  - a second electrode ~~on the organic emitting layer~~ having a stack of at least one transparent thin film layer on the organic emitting layer;  
wherein the transparent thin film layer of the second electrode includes a first layer of a metal, and a second layer of a transparent material; and  
wherein the first layer and the second layer are stacked alternately.
2. (Currently Amended) The device as claimed in claim 1, wherein the first electrode is formed of a material selected from the group consisting of ITO, Al, and Ag.
3. (Original) The device as claimed in claim 1, wherein the organic emitting layer

includes a stack of a hole injecting layer, a hole transport layer, an emitting layer, an electron transport layer, and an electron injecting layer formed on the first electrode or the second electrode in succession.

4. (Canceled)

5. (Canceled)

6. (Currently Amended) The device as claimed in claim [[4]] 1, wherein the first layer is formed of a material selected from Ag, Al, Cr, Mo, Au, Pt, Sn, Ln, ~~and~~ Mg, ~~and~~ Al:Li, Ag:Mg, ~~and~~ or Ag:Li [[,]]; and the second layer is formed of a material selected from ITO, IZO, TiO<sub>2</sub>, SiO<sub>2</sub>, ~~and~~ or Si<sub>3</sub>N<sub>4</sub>.

7. (Currently Amended) The device as claimed in claim [[4]] 1, wherein the transparent thin film layer of the second electrode includes 1 - 100 layers in total.

8. (Currently Amended) The device as claimed in claim 1, further comprising a protection layer film having at least one transparent thin film layer on the second electrode ~~having at least one transparent thin film layer.~~

9. (Original) The device as claimed in claim 8, wherein the transparent thin film layer of the protection film includes four layers in total.

10. (Currently Amended) The device as claimed in claim 9, wherein the first layer of the protection film is formed of a material selected from a polymer ~~including~~ having a fluorine, ~~stearyl~~ stearyl acrylate, lauryl acrylate, 2-phenoxyethyl acrylate, isodecyl acrylate, isooctyl acrylate, iso bornyl acrylate, 1,3-butylene glycol acrylate, 1,4-butanediol diacrylate, 1,6-hexanediol diacrylate, ethoxylated bisphenol A diacrylate, propoxylated neophentyl glycol diacrylate, tris(2-hydroxyethyl) isocyanurate triacrylate, ~~and or~~ or trimethylolpropane triacrylate[[,]]; the second layer of the protection film is formed of a material selected from SiC, SiO, SiO<sub>2</sub>, ~~and or~~ or Si<sub>x</sub>N<sub>y</sub>[[,]]; the third layer of the protection film is formed of a sealant of a silicon compound of an expoxy group or an acryl group[[,]]; and the fourth layer of the protection film is formed of a material selected from PET, PMMA, ~~and or~~ or a polymer ~~of~~ having a fluorine group.

11. (Currently Amended) An organic EL device comprising:

- a substrate;
- a first electrode on the substrate;
- an organic emitting layer on the first electrode;
- a second electrode having an alternate stack of at least one metal layer and at least a

transparent thin film layer on the organic emitting layer ~~having alternate stack of at least one metal layer and at least a transparent thin film layer;~~ and

a protection film having a stack of at least one transparent thin film layer on the second electrode ~~having a stack of at least one transparent thin film layer.~~

12. (Currently Amended) The device as claimed in claim 11, wherein the first electrode is formed of a material selected from the group consisting of ITO, Al, and Ag.

13. (Original) The device as claimed in claim 11, wherein the organic emitting layer includes a stack of a hole injecting layer, a hole transport layer, an emitting layer, an electron transport layer, and an electron injecting layer formed on the first electrode or the second electrode in succession.

14. (Currently Amended) The device as claimed in claim 11, wherein the metal layer of the second electrode is formed of a material selected from Ag, Al, Cr, Mo, Au, Pt, Sn, Ln, ~~and~~ Mg, ~~and~~ Al:Li, Ag:Mg, ~~and or~~ Ag:Li[[,]]; and the transparent thin film layer is formed of a material selected from ITO, ZnO, TiO<sub>2</sub>, SiO<sub>2</sub>, ~~and or~~ Si<sub>3</sub>N<sub>4</sub>.

15. (Original) The device as claimed in claim 11, wherein the second electrode includes 1 - 100 layers in total.

16. (Original) The device as claimed in claim 11, wherein the transparent thin film layer of the protection film includes four layers in total.

17. (Currently Amended) The device as claimed in claim 16, wherein the first layer of the protection film is formed of a material selected from a polymer ~~including~~ having a fluorine, ~~stearyl~~ stearyl acrylate, lauryl acrylate, 2-phenoxyethyl acrylate, isodecyl acrylate, isooctyl acrylate, isobornyl acrylate, 1,3-butylene glycol acrylate, 1,4-butanediol diacrylate, 1,6-hexanediol diacrylate, ethoxylated bisphenol A diacrylate, propoxylated neophentyl glycol diacrylate, tris(2-hydroxyethyl) isocyanurate triacrylate, ~~and or~~ or trimethylolpropane triacrylate[[,]]; the second layer of the protection film is formed of a material selected from SiC, SiO, SiO<sub>2</sub>, ~~and or~~ or Si<sub>x</sub>N<sub>y</sub>[[,]]; the third layer of the protection film is formed of a sealant of a silicon compound of an epoxy group or an acryl group[[,]]; and the fourth layer of the protection film is formed of a material selected from PET, PMMA, ~~and or~~ or a polymer ~~of a~~ having a fluorine group.

18. (New) The device as claimed in claim 1, wherein the second electrode comprises two or more sets of the first layer and the second layer stack alternately.

19. (New) The device as claimed in claim 11, wherein the second electrode comprises a plurality of said alternate stacks of said at least one metal layer and said at least one transparent thin film layer.

20. (New) An organic EL device comprising:

- a substrate;
- a first electrode on the substrate;
- an organic emitting layer on the first electrode;
- a second electrode having a plurality of alternate stacks, wherein each alternate stack includes at least one metal layer and at least a transparent thin film layer on the organic emitting layer; and
- a protection film on the second electrode having a stack of at least one transparent thin film layer.